

L Number	Hits	Search Text	DB	Time stamp
-	441	(349/188-192).CCLS.	USPAT; US-PGPUB; JPO	2004/03/11 14:45
-	0	((("349/188-192").CCLS.) and "in line system"	USPAT; US-PGPUB; JPO	2001/11/29 14:28
-	0	((("349/188-192").CCLS.) and "in-line system"	USPAT; US-PGPUB; JPO	2001/11/29 14:28
-	8	((("349/188-192").CCLS.) and "production line"	USPAT; US-PGPUB; JPO	2001/11/29 14:30
-	2	((("349/188-192").CCLS.) and "assembly line"	USPAT; US-PGPUB; JPO	2001/11/29 14:31
-	5	((("349/188-192").CCLS.) and "manufacturing line" "line of manufacture")	USPAT; US-PGPUB; JPO	2001/11/29 14:32
-	14	((("349/188-192").CCLS.) and "production line") ((("349/188-192").CCLS.) and "assembly line") ((("349/188-192").CCLS.) and ("manufacturing line" "line of manufacture"))	USPAT; US-PGPUB; JPO	2001/11/29 14:32
-	0	((("349/188-192").CCLS.) and "production line") ((("349/188-192").CCLS.) and "assembly line") ((("349/188-192").CCLS.) and ("manufacturing line" "line of manufacture")) and ("spacer dispensing" "spacer dispersing")	USPAT; US-PGPUB; JPO	2001/11/29 14:33
-	10	((("349/188-192").CCLS.) and "production line") ((("349/188-192").CCLS.) and "assembly line") ((("349/188-192").CCLS.) and ("manufacturing line" "line of manufacture")) and (machine apparatus station)	USPAT; US-PGPUB; JPO	2001/11/29 14:34
-	478	(349/188-192).CCLS.	USPAT; US-PGPUB; JPO	2002/07/15 08:48
-	0	((349/188-192).CCLS.) and phillips..as.	USPAT; US-PGPUB; EPO; JPO	2002/07/15 08:49
-	0	((349/188-192).CCLS.) and phillips.as.	USPAT; US-PGPUB; EPO; JPO	2002/07/15 08:49
-	0	((349/188-192).CCLS.) and phillips.astx.	USPAT; US-PGPUB; EPO; JPO	2002/07/15 08:51
-	3	((349/188-192).CCLS.) and "deposit liquid crystal"	USPAT; US-PGPUB; EPO; JPO	2002/07/15 09:47
-	1	("6414733").PN.	USPAT; US-PGPUB; EPO; JPO	2002/07/15 09:47
-	4	((349/188-192).CCLS.) and "deposit liquid crystal") (("6414733").PN.)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 08:40
-	1084	(349/153).CCLS.	USPAT; US-PGPUB; EPO; JPO	2002/07/15 09:51
-	0	((349/153).CCLS.) and "first hardening"	USPAT; US-PGPUB; EPO; JPO	2002/07/15 09:53
-	0	((349/153).CCLS.) and "reaction prevention"	USPAT; US-PGPUB; EPO; JPO	2002/07/15 09:53
-	0	((349/153).CCLS.) and "pre polymerize"	USPAT; US-PGPUB; EPO; JPO	2002/07/15 09:54

-	0	((349/153).CCLS.) and "pre-polymerize"	USPAT; US-PGPUB; EPO; JPO	2002/07/15 09:54
-	52	((349/153).CCLS.) and contamination	USPAT; US-PGPUB; EPO; JPO	2002/07/15 09:54
-	27854	349\$.ccls.	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:19
-	358	349\$.ccls. and (rotat\$5 near3 substrate)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:20
-	574	349\$.ccls. and (spin\$3 near3 substrate)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:21
-	260	(349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:22
-	422	(349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:21
-	231	((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:22
-	151	((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:22
-	106	((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:23
-	103	((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)) and ("liquid crystal" same spin\$3)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:24
-	204	((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5)) (((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)) and ("liquid crystal" same spin\$3))	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:24
-	174	((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5)) (((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)) and ("liquid crystal" same spin\$3))) and @ad<20000419	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:29
-	147	((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5)) (((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)) and ("liquid crystal" same spin\$3))) and @ad<20000419) not (resist same spin\$3)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:30
-	147	((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5)) (((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)) and ("liquid crystal" same spin\$3))) and @ad<20000419) not (resist same spin\$3)) not (resist same rotat\$5)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:31

-	146	(((((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5)) (((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)) and ("liquid crystal" same spin\$3))) and @ad<20000419) not (resist same spin\$3)) not (resist same rotat\$5)) not (photo same rotat\$5))	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:32
-	123	(((((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5)) (((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)) and ("liquid crystal" same spin\$3))) and @ad<20000419) not (resist same spin\$3)) not (resist same rotat\$5)) not (photo same rotat\$5)) not (polymer same rotat\$5))	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:32
-	119	(((((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5)) (((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)) and ("liquid crystal" same spin\$3))) and @ad<20000419) not (resist same spin\$3)) not (resist same rotat\$5)) not (photo same rotat\$5)) not (polymer same rotat\$5)) not (photo same spin\$3))	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:33
-	97	(((((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5)) (((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)) and ("liquid crystal" same spin\$3))) and @ad<20000419) not (resist same spin\$3)) not (resist same rotat\$5)) not (photo same rotat\$5)) not (polymer same rotat\$5)) not (photo same spin\$3)) not (polymer same spin\$3))	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:34
-	1	(((((349\$.ccls. and (rotat\$5 near3 substrate)) and (rotat\$5 near2 substrate)) and (rotat\$5 near substrate)) and ("liquid crystal" same rotat\$5)) (((349\$.ccls. and (spin\$3 near3 substrate)) and (spin\$3 near2 substrate)) and (spin\$3 near substrate)) and ("liquid crystal" same spin\$3))) and @ad<20000419) not (resist same spin\$3)) not (resist same rotat\$5)) not (photo same rotat\$5)) not (polymer same rotat\$5)) not (photo same spin\$3)) not (polymer same spin\$3)) and (fill same (rotat\$5 spin\$3))	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:36
-	137	(349/189).CCLS.	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:36
-	1	((349/189).CCLS.) and (fill same (rotat\$5 spin\$3))	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:37
-	43	((349/189).CCLS.) and (rotat\$5 spin\$3)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:38
-	32	((349/189).CCLS.) and (rotat\$5 spin\$3)) and ((rotat\$5 spin\$3) same liquid)	USPAT; US-PGPUB; EPO; JPO	2002/07/16 07:39

-	2	("5461502").PN.	USPAT; US-PGPUB; EPO; JPO	2002/07/16 08:40
-	1	"09/838,385"	USPAT; US-PGPUB; EPO; JPO	2002/11/25 10:45
-	499	(349/188-192).CCLS.	USPAT; US-PGPUB; JPO	2002/11/25 13:16
-	531	(349/188-192).CCLS.	USPAT; US-PGPUB; JPO	2003/07/10 11:20
-	34	((349/188-192).CCLS.) not @pd<20021101	USPAT; US-PGPUB; EPO; JPO	2003/07/10 11:20
-	2	"09/838385"	USPAT; US-PGPUB; EPO; JPO	2004/03/11 14:46